

IN THE SPECIFICATION

Please amend paragraph [0012] as follows:

[0012] The preferred method of delivery, as described above, is through a chemical vapor deposition process, in an on-line float glass production process. Some possible methods of preparing precursors for use in the CVD process can include the use of a bubbler as well as solution delivery in conjunction with a thin film evaporator. U.S. Patent No. 6,521,295 (column 3, line 60 etc.) discloses such a process and is hereby incorporated by reference as if set forth in its entirety herein. US 6,521,295 discloses that an organoantimony-containing reactant stream is combined with the organotin reactant stream at a point prior to delivery of the reactants to the surface of the hot glass substrate upon which the coating is to be deposited. After combination, the vaporized reactants of organotin, organoantimony, water and an oxygen-containing compound are delivered to the surface of the hot glass, where they react together to deposit thereon a coating of antimony doped tin oxide. US 6,521,295 further teaches that the resulting gaseous reactant stream of organoantimony and water vapor is combined with the gaseous organotin reactant stream to form a uniform, gaseous reactant stream. The uniform, gaseous reactant stream is delivered to the surface of the hot glass substrate.